

WHAT IS CLAIMED IS:

1 1. A magnetoresistive head comprising:
2 an antiferromagnetic layer;
3 a pinned layer formed on the antiferromagnetic layer with a magnetizing
4 direction of the pinned layer being fixed;
5 a nonmagnetic layer formed on the pinned layer;
6 a free layer formed on the nonmagnetic layer;
7 a magnetic domain control film for magnetic domain control of the free layer;
8 and a pair of electrode films for supplying electric current to a stack of the
9 antiferromagnetic layer, the pinned layer, the nonmagnetic layer, and the free layer;
10 wherein, when a width of the free layer as viewed from an air bearing surface
11 is defined as a geometrical track width $Twr_geo(nm)$ and expressed as x , a magnetization
12 film thickness product $Br \cdot t(G \cdot \mu m)$ of the magnetic domain control film and x satisfy the
13 following:
14 $-2.94 \cdot 10^{-4}x^3 + 8.54 \cdot 10^{-2}x^2 - 5.73x + 116 \leq Br \cdot t < 3.75 \cdot 10^{-1}x + 130$ and $40 \leq x < 160$.

1 2. A magnetoresistive head comprising:
2 an antiferromagnetic layer;
3 a pinned layer formed on the antiferromagnetic layer with a magnetizing
4 direction of the pinned layer being fixed;
5 a nonmagnetic layer formed on the pinned layer;
6 a free layer formed on the nonmagnetic layer;
7 a magnetic domain control film for magnetic domain control of the free layer;
8 and
9 a pair of electrode films for supplying electric current to a stack of the
10 antiferromagnetic layer, the pinned layer, the nonmagnetic layer, and the free layer;
11 wherein, when a width of the free layer as viewed from an air bearing surface
12 is defined as a geometrical track width $Twr_geo(nm)$ and expressed as x , a magnetization
13 film thickness product $Br \cdot t(G \cdot \mu m)$ of the magnetic domain control film and x satisfy the
14 following:
15 $-2.94 \cdot 10^{-4}x^3 + 8.54 \cdot 10^{-2}x^2 - 5.73x + 116 \leq Br \cdot t \leq -2.94 \cdot 10^{-4}x^3 + 8.54 \cdot 10^{-2}x^2 - 5.73x +$
16 $141, Br \cdot t < 3.75 \cdot 10^{-1}x + 130$, and $40 \leq x < 160$.

3. A magnetoresistive head comprising:
 an antiferromagnetic layer;
 a pinned layer formed on the antiferromagnetic layer with a magnetizing
 direction of the pinned layer being fixed;
 a nonmagnetic layer formed on the pinned layer;
 a free layer formed on the nonmagnetic layer;
 a magnetic domain control film for magnetic domain control of the free layer;
 and
 a pair of electrode films for supplying electric current to a stack of the
 antiferromagnetic layer, the pinned layer, the nonmagnetic layer, and the free layer;
 wherein, when a width of the free layer as viewed from an air bearing surface
 is defined as a geometrical track width $Twr_geo(nm)$ and expressed as x , a magnetization
 film thickness product $Br \cdot t (G \cdot \mu m)$ of the magnetic domain control film and x satisfy the
 following:

$$-2.94 \cdot 10^{-4}x^3 + 8.54 \cdot 10^{-2}x^2 - 5.73x + 151 \leq Br \cdot t < 3.75 \cdot 10^{-1}x + 165 \text{ and } 40 \leq x < 160.$$

4. A magnetoresistive head comprising:
 an antiferromagnetic layer;
 a pinned layer formed on the antiferromagnetic layer with a magnetizing
 direction of the pinned layer being fixed;
 a nonmagnetic layer formed on the pinned layer;
 a free layer formed on the nonmagnetic layer;
 a magnetic domain control film for magnetic domain control of the free layer;
 and
 a pair of electrode films for supplying electric current to a stack of the
 antiferromagnetic layer, the pinned layer, the nonmagnetic layer, and the free layer;
 wherein, when a width of the free layer as viewed from an air bearing surface
 is defined as a geometrical track width $Twr_geo(nm)$ and expressed as x , a magnetization
 film thickness product $Br \cdot t (G \cdot \mu m)$ of the magnetic domain control film and x satisfy the
 following:

$$-2.94 \cdot 10^{-4}x^3 + 8.54 \cdot 10^{-2}x^2 - 5.73x + 151 \leq Br \cdot t \leq -2.94 \cdot 10^{-4}x^3 + 8.54 \cdot 10^{-2}x^2 - 5.73x + 176, Br \cdot t < 3.75 \cdot 10^{-1}x + 165, \text{ and } 40 \leq x < 160.$$

5. A magnetoresistive head comprising:
 an underlying layer;
 a free layer formed on the underlying layer;
 a magnetic domain control film for magnetic domain control of the free layer;
 a nonmagnetic layer formed on the free layer;
 a pinned layer formed on the nonmagnetic layer with a magnetizing direction
 of the pinned layer being fixed;
 an antiferromagnetic layer fixing magnetization of the pinned layer; and
 a pair of electrode films for supplying electric current to a stack of the
 underlying layer, the free layer, the nonmagnetic layer, the pinned layer and the
 antiferromagnetic layer;
 wherein, when a width of the free layer as viewed from an air bearing surface
 is defined as a geometrical track width $Twr_geo(nm)$ and expressed as x , a magnetization
 film thickness product $Br \cdot t(G \cdot \mu m)$ of the magnetic domain control film and x satisfy the
 following:
 $-2.94 \cdot 10^{-4}x^3 + 8.54 \cdot 10^{-2}x^2 - 5.73x + 116 \leq Br \cdot t < 3.75 \cdot 10^{-1}x + 130$ and $40 \leq x < 160$.

6. A magnetoresistive head comprising:
 an underlying layer;
 a free layer formed on the underlying layer;
 a magnetic domain control film for magnetic domain control of the free layer;
 a nonmagnetic layer formed on the free layer;
 a pinned layer formed on the nonmagnetic layer with a magnetizing direction
 of the pinned layer being fixed;
 an antiferromagnetic layer fixing magnetization of the pinned layer; and
 a pair of electrode films for supplying electric current to a stack of the
 underlying layer, the free layer, the nonmagnetic layer, the pinned layer and the
 antiferromagnetic layer;
 wherein, when a width of the free layer as viewed from an air bearing surface
 is defined as a geometrical track width $Twr_geo(nm)$ and expressed as x , a magnetization
 film thickness product $Br \cdot t(G \cdot \mu m)$ of the magnetic domain control film and x satisfy the
 following:

16 $-2.94 \cdot 10^{-4}x^3 + 8.54 \cdot 10^{-2}x^2 - 5.73x + 116 \leq Br \cdot t \leq -2.94 \cdot 10^{-4}x^3 + 8.54 \cdot 10^{-2}x^2 - 5.73x +$
17 $141, Br \cdot t < 3.75 \cdot 10^{-1}x + 130, \text{ and } 40 \leq x < 160.$

1 7. A magnetoresistive head comprising:
2 an underlying layer;
3 a free layer formed on the underlying layer;
4 a magnetic domain control film for magnetic domain control of the free layer;
5 a nonmagnetic layer formed on the free layer;
6 a pinned layer formed on the nonmagnetic layer with a magnetizing direction
7 of the pinned layer being fixed;
8 an antiferromagnetic layer fixing magnetization of the pinned layer; and
9 a pair of electrode films for supplying electric current to a stack of the
10 underlying layer, the free layer, the nonmagnetic layer, the pinned layer and the
11 antiferromagnetic layer;
12 wherein, when a width of the free layer as viewed from an air bearing surface
13 is defined as a geometrical track width $Twr_geo(nm)$ and expressed as x , a magnetization
14 film thickness product $Br \cdot t(G \cdot \mu m)$ of the magnetic domain control film and x satisfy the
15 following:
16 $-2.94 \cdot 10^{-4}x^3 + 8.54 \cdot 10^{-2}x^2 - 5.73x + 151 \leq Br \cdot t < 3.75 \cdot 10^{-1}x + 165$ and $40 \leq x < 160.$

1 8. A magnetoresistive head comprising:
2 an underlying layer;
3 a free layer formed on the underlying layer;
4 a magnetic domain control film for magnetic domain control of the free layer;
5 a nonmagnetic layer formed on the free layer;
6 a pinned layer formed on the nonmagnetic layer with a magnetizing direction
7 of the pinned layer being fixed;
8 an antiferromagnetic layer fixing magnetization of the pinned layer; and
9 a pair of electrode films for supplying electric current to a stack of the
10 underlying layer, the free layer, the nonmagnetic layer, the pinned layer and the
11 antiferromagnetic layer;
12 wherein, when a width of the free layer as viewed from an air bearing surface
13 is defined as a geometrical track width $Twr_geo(nm)$ and expressed as x , a magnetization

14 film thickness product $Br \cdot t (G \cdot \mu m)$ of the magnetic domain control film and x satisfy the
15 following:
16 $-2.94 \cdot 10^{-4} x^3 + 8.54 \cdot 10^{-2} x^2 - 5.73x + 151 \leq Br \cdot t \leq -2.94 \cdot 10^{-4} x^3 + 8.54 \cdot 10^{-2} x^2 - 5.73x +$
17 $176,$
18 $Br \cdot t < 3.75 \cdot 10^{-1} x + 165,$ and $40 \leq x < 160.$

1 9. A magnetoresistive head comprising:
2 an insulative layer formed on a substrate;
3 an antiferromagnetic layer formed on the insulative layer;
4 a pinned layer formed on the antiferromagnetic layer with a magnetizing
5 direction of the pinned layer being fixed;
6 a nonmagnetic layer formed on the pinned layer;
7 a free layer formed on the nonmagnetic layer;
8 a pair of electrode films for supplying electric current to a stack of the
9 antiferromagnetic layer, the pinned layer, the nonmagnetic layer and the free layer; and
10 an electrode underlying film;
11 wherein the electrode underlying film is formed directly on the insulative film
12 in a case where a width of the free layer as viewed from an air bearing surface is defined as
13 Twr_geo (nm) and expressed as x , and $x < 40.$

1 10. A magnetoresistive head according to any one of claims 1 to 8, wherein
2 the magnetic domain control film comprises a magnetic film made of a CoPt alloy
3 comprising at least 4 to 30 at% of Pt, or a CoCrPt alloy, or CoCrPt-ZrO₂ or CoCrPt-SiO₂
4 further comprising 2 to 15 at% of Cr.

1 11. A magnetoresistive head according to any one of claims 1 to 8, wherein
2 the magnetic domain control film comprises a stacked film in which at least two or more
3 magnetic films are antiferromagnetically coupled by way of a nonmagnetic film comprising
4 Ru, Cr, Ir, Rh, Os, Re, Au, Ag, Cu or an alloy thereof, and a magnetic film as a constituent
5 element thereof is a magnetic film comprising a CoPt alloy comprising at least 4 to 30 at% of
6 Pt, or a CoCrPt alloy, or CoCrPt-ZrO₂ or CoCrPt-SiO₂ further comprising 2 to 15 at% of Cr
7 or a magnetic film having soft magnetic property containing Fe or Ni.

1 12. A magnetoresistive head according to any one of claims 1 to 8, wherein
2 the magnetic domain control film is a stacked film having two-layers of magnetic films

antiferromagnetically coupled by way of a nonmagnetic film, and the magnetization film thickness product $Br \cdot t$ of the magnetic domain control film is defined as

$$Br \cdot t = Br1 \cdot t1 - Br2 \cdot t2$$

assuming residual magnetic flux densities of the two layers of magnetic layers as $Br1$ and $Br2$, respectively, and film thicknesses thereof as $t1$ and $t2$, respectively.

13. A magnetoresistive head according to any one of claims 1 to 8, wherein the magnetic domain control film is a stacked film having three layers of magnetic films and antiferromagnetically coupled by way of a nonmagnetic film, and the magnetization film thickness product $Br \cdot t$ of the magnetic domain control film is defined as

$$Br \cdot t = Br1 \cdot t1 - Br2 \cdot t2 + Br3 \cdot t3$$

assuming residual magnetic flux densities of the three magnetic layers as $Br1$, $Br2$, and $Br3$, respectively, and the film thicknesses thereof as $t1$, $t2$, and $t3$, respectively.

14. A magnetic head having a magnetoresistive head according to any one of claims 1 to 8 having as a reading head and having a writing head for in-plane recording.

15. A magnetic head having a magnetoresistive head according to any one of claims 1 to 8 as a reading head and having a writing head for perpendicular recording.